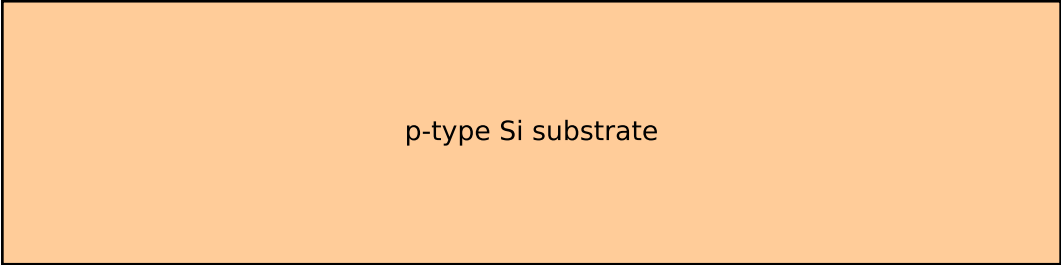


1.1 — Pre-oxidation clean (HF-last)



p-type Si substrate